

process.

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Cond 63. (New) A device manufacturing method including a lithographic process, wherein exposure is performed using said exposure apparatus according to Claim 51 in said lithographic process.--

REMARKS

Claims 1-24 and 44-63 are presently active in this case. The 2nd Claim 24 and Claims 25-43 have been canceled and Claims 44 - 63 have been added by way of the present amendment.

An early and favorable action is respectfully requested.

Respectfully submitted,

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